

L Number	Hits	Search Text	DB	Time stamp
2	518	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:25
3	2	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography) same (photoresist or resist\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:26
4	51	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography) near5 grad\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:41
5	1	((dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography) near5 grad\$4) and 438\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:28
6	1	((dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography)) and 438\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:28
7	6	((dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography)) and 257\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:29
8	3	((dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near10 (\$1HPLC\$1 or pressure near2 liquid adj chromatography)) and semiconductor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:29
9	0	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") near5 grad\$4 same (resist or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:44
10	332	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") same (resist or photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:44
11	1	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmsu or "c.sub.2h.sub.6os") same (resist or photoresist) same chromatography	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/09/11 13:44